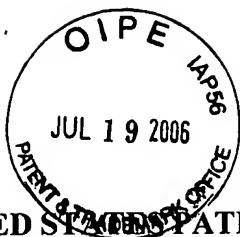


Docket No.: 050212-0559



PATENT

FILED
JULY 19 2006
U.S. PATENT AND TRADEMARK OFFICE

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of : Customer Number: 20277
Yoshiaki NISHIBAYASHI, et al. : Confirmation Number: 1031
Application No.: 10/774,417 : Group Art Unit: 1763
Filed: February 10, 2004 : Examiner: Olsen, Allan W.
For: METHOD OF MAKING DIAMOND PRODUCT AND DIAMOND PRODUCT

INFORMATION DISCLOSURE STATEMENT

Mail Stop IDS
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed more than three months after the U.S. filing date AND after the mailing date of the first Office Action on the merits, but before the mailing date of a Final Rejection or Notice of Allowance.

3

CERTIFICATION PARAGRAPH

The undersigned certifies that each item of information contained in this Information Disclosure Statement was first cited in a communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of this Information Disclosure Statement as described in 37 CFR 1.97(e)(1).

Each reference was cited in a corresponding foreign application search report or office action and its relevance discussed therein. A copy of the foreign search report or office action is attached for the Examiner's information. Please note that all the reference list on page 1 of the "documents considered to be relevant" on the search report filed herewith, were filed with an Information Disclosure Statement filed on March 10, 2006.

Please charge any shortage in fees due in connection with the filing of this paper, including extension of time fees, to Deposit Account 500417 and please credit any excess fees to such deposit account.

Respectfully submitted,

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Date: July 19, 2006

**Please recognize our Customer No. 20277
as our correspondence address.**



SHEET 1 OF 1

INFORMATION DISCLOSURE CITATION IN AN APPLICATION (PTO-1449)			ATTY. DOCKET NO. 050212-0559	SERIAL NO. 10/774,417
			APPLICANT Yoshiaki NISHIBAYASHI, et al.	
			FILING DATE February 10, 2004	GROUP 1763
U.S. PATENT DOCUMENTS				
EXAMINER'S INITIALS	CITE NO.	Document Number Number-Kind Code ₂ (<i>if known</i>)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document
		US		
FOREIGN PATENT DOCUMENTS				
EXAMINER'S INITIALS	CITE NO.	Foreign Patent Document Country Codes-Number & Kind Codes (<i>if known</i>)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)				
EXAMINER'S INITIALS	CITE NO.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.		
		Hong J. et al, "Etching process of hydrogenated amorphous carbon (a-C:H) thin films in a dual ECR-r.f. nitrogen plasma", vol. 8, no. 2-5, March 1999, pages 572-576, XP004364947		
		Basche B., "Optische Emissionsspektroskopie Zum Analysieren Von Plasma", vol. 98, no. 6, 1 June 1990, pages 272-274, XP000132699		
		Valyi G. et al, "Analysis of chemical processes of plasma etching", vol. 76, no. 3, 13 February 1981, pages 215-219, XP002381595		
		Search Report dated June 21, 2006		
EXAMINER			DATE CONSIDERED	

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered.
 Include copy of this form with next communication to applicant.

1 Applicant's unique citation designation number (optional). 2 Applicant is to place a check mark here if English language Translation is attached.